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Patent
Attorney Docket No. 51890

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of)	
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Kei ARAO et al)	Group Art Unit: 1752
)	
Application No: 10/768,940)	Examiner: Amanda C. Walke
)	
Filed: January 30, 2004)	Confirmation No: 7175
)	
FOR: NEGATIVE-TYPE)	
PHOTOSENSITIVE RESIN)	
COMPOSITION CONTAINING)	
EPOXY COMPOUND)	

SUPPLEMENTAL AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

Further to the Amendment filed March 14, 2005, applicants submit the following supplemental amendments and remarks.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 3 of this paper.